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Niobium oxide coatings on nanostructured platinum electrocatalysts: benefits and limitations†

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Development of durable nanoscale electrocatalysts is an important step towards improving the affordability and sustainability of fuel cell technology. Nanostructured platinum catalysts are used to facilitate the two half reactions for hydrogen fuel cells. The sluggish kinetics of the cathodic oxygen reduction reaction and the less than optimal stability of cathode catalysts provide motivation for additional efforts to improve the catalytic performance of platinum. Metal oxide coatings on electrocatalysts have been found to increase durability of nanostructured catalysts and to impart additional properties such as increased activity and resistance to poisoning by contaminants. Niobium oxides have been studied as supporting materials for platinum fuel cell catalysts and shown to have a relatively high stability. It has also been suggested that niobium oxides can impart an increased activity due to strong metal support interactions. However, the lack of electrical conductivity of niobium pentoxide limits its viability as a support. Herein, coatings of niobium oxide were applied to nanotextured platinum catalysts prepared by electrodeposition against self-assembled templates to explore the impact of the coatings on the durability and electrocatalytic activity of the catalyst both during and after an accelerated stress test. The catalysts were characterized via scanning electron microscopy, X-ray photoelectron spectroscopy, conductive atomic force microscopy, and electrochemical techniques. Increasing the thickness of the coating from ~0.5 nm to ~4.5 nm was found to preserve the initial nanostructured morphology of the electrodeposited platinum catalyst. The thicker coatings did, however, result in larger charge transfer resistances towards the oxygen reduction reaction. These studies provide further evidence of the utility of ultrathin coatings to improve the properties of nanostructured electrocatalysts.

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Introduction

Nanoscale particles and nanostructures have long been a subject of interest in heterogeneous catalysis. This interest stems from the high surface areas and activities of these materials relative to bulk materials. Platinum nanoparticles are currently used commercially in hydrogen-based polymer electrolyte membrane (PEM) fuel cell technologies. The development and implementation of these low temperature hydrogen fuel cells is a vital part of shifting our dependence from fossil fuels to renewable energy sources.^{1,2} The high

price of platinum is a motivating factor for optimizing the use of platinum and ensuring that the platinum within the PEM fuel cell retains as much of its initial activity for as long as possible. These motivations have led to many studies being performed to understand how these nanoparticle catalysts behave over the lifetime of a fuel cell and, specifically, what these behaviours mean in terms of catalytic performance. Over the course of fuel cell operation, platinum nanoparticles are known to lose activity by coalescing and forming larger particles, which results in an overall decrease in surface area. These catalysts can also lose activity through poisoning by contaminants, as well as through dissolution and a subsequent deposition onto other particles (Ostwald ripening) or migration into other components within the PEM fuel cell.^{3,4} These degradation mechanisms are most prevalent at the cathode of the PEM fuel cell where the oxygen reduction reaction (ORR) takes place. Platinum degradation is often a result of the formation of platinum oxide, which plays a central role in platinum dissolution.⁵ Minimization of platinum re-structuring is especially of interest for platinum catalysts prepared as nanostructured thin films (NSTFs) such

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Niobium oxide was chosen as the coating material for platinum catalysts in this study. This oxide has previously been explored as a platinum catalyst support in PEM fuel cells and was shown to stabilize platinum nanoparticles and increase their activity towards the ORR, which was attributed to strong metal support interactions.^{22,23} Niobium oxide also has a high stability and corrosion resistance under a variety of operating conditions including at elevated temperatures and relatively high acidities.^{24,25} This type of coating would be of interest for catalysts composed of either Pt nanoparticles supported on conductive carbon substrates, or a mesoporous Pt film (*e.g.*, a NSTF) such that electron conduction does not need to occur through the electrically insulating Nb₂O₅ coating.^{6,7,26,27} An experimental design was, therefore, created to evaluate a series of Nb₂O₅ films of different thickness to assess their influence on charge transfer resistance during the ORR, as well as their ability to stabilize the Pt catalyst. Atomic layer deposition (ALD) was selected as the method to prepare these layers since this

A high surface area, nanostructured Pt catalyst was prepared *via* electrodeposition onto a planar Pt film supported on a polished Si wafer. The electrodeposition of the nanostructured Pt was carried out over 150 s using a double-pulse or two-step process (Fig. 1a). Initially, a high overpotential was applied over a relatively short duration, in this case $-0.6 \text{ V}_{\text{Ag}/\text{AgCl}}$ for 30 s, followed by the application of a lower overpotential growth potential over a longer duration, $-0.2 \text{ V}_{\text{Ag}/\text{AgCl}}$ for 120 s.^{27,33} Higher overpotentials were not used for the nucleation stage of

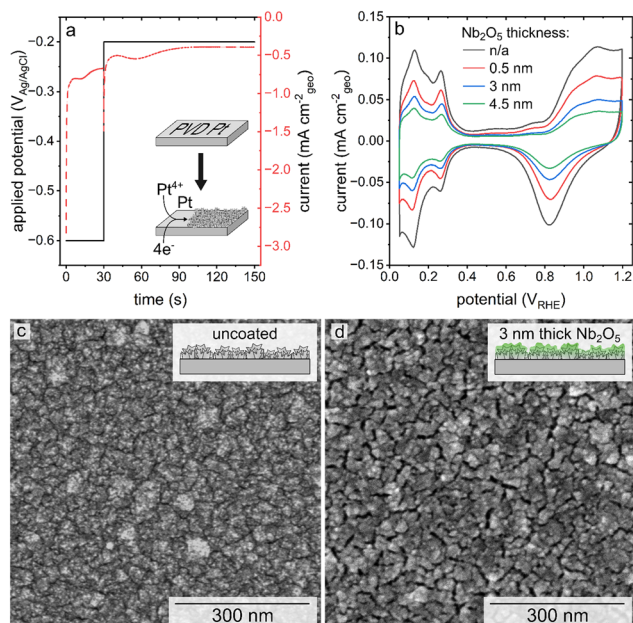


Fig. 1 (a) Current density and potential recorded as a function of time during the sequential, double pulse electrodeposition of a textured Pt catalyst. (b) A series of cyclic voltammograms corresponding to the textured Pt catalysts (both without and with niobia or Nb_2O_5 coatings as indicated in the legend) before an accelerated stress test (AST). Scanning electron microscopy (SEM) images of pristine Pt with a nanoscale texture (c) and the same substrate after coating with a 3 nm thick layer of Nb_2O_5 (d).

this process because it was found that more reducing potentials than $-0.6 \text{ V}_{\text{Ag/AgCl}}$ resulted in hydrogen gas evolution. This gas evolution resulted in the formation of a less uniform layer of porous Pt upon the substrate. The double-pulse, or two-stage electrodeposition process was used to prepare the mesoporous Pt with a nanoscale texture upon a layer of Pt prepared by PVD techniques. The resulting texture of the electrodeposited Pt layer was characterized by scanning electron microscopy (SEM) based techniques (Fig. 1c). The Pt catalyst was electrodeposited in the presence of Brij-78, a pore-forming agent, to further increase the active surface area of the catalyst from $\sim 6 \text{ cm}^2$ to $\sim 9 \text{ cm}^2$.^{27,29} The area measured by integration of the profiles recorded during electrodeposition is correlated to the charge passed during the formation of these textured Pt films. Assuming an efficient 4-electron process during electrodeposition ($\text{Pt}^{4+} + 4\text{e}^- \rightarrow \text{Pt}$), the average mass of Pt electrodeposited onto each $1 \times 1 \text{ cm}^2$ substrates was $42 \pm 2 \mu\text{g cm}^{-2}$. This process was used to prepare a series of Pt catalysts with nanoscale textured morphologies. A series of these nanostructured Pt catalysts were coated with Nb_2O_5 films. Thickness of the niobia layer was progressively tuned to achieve a set of samples for comparing the relative influence of its thickness on Pt activity and durability.

Atomic layer deposition was selected for creating the ultrathin coatings of Nb_2O_5 on the nanostructured Pt due to the relatively high degree of control of ALD over the thickness of the deposited layers, as well as its reported ability to prepare uniform and conformal films.^{28,34,35} The Nb_2O_5 coatings were

targeted to have a nominal thickness of 0.5 nm, 3 nm, and 4.5 nm based on previously established methods.³⁰ Representative SEM images of the electrodeposited Pt after applying the Nb_2O_5 coating (Fig. 1d, S1†) demonstrate the presence of visible recesses between the nanoscale features of these nanotextured films. These recesses follow a similar pattern to the grains of the PVD Pt that lies beneath (Fig. S2a†). Control experiments were performed to evaluate if the process of heating the substrates to 250°C during the ALD process resulted in the formation of these recesses. In this control study, a sample of electrodeposited Pt was subjected to the same thermal cycles as performed during the ALD process. As shown in Fig. S2b†, similar recesses in the electrodeposited Pt can be seen after this thermal treatment demonstrating that they are a product of the ALD conditions and not specifically the deposition of the Nb_2O_5 . The morphology of the coated samples also appears to have a relatively smooth topography in comparison to the features observed before applying the niobia coating, which could be a function of the oxide coating and/or the differences in electron conduction of the Pt and the Nb_2O_5 (e.g., relatively minor charging in the oxide coated regions of the substrates). It is notable that the ‘smoothness’ of the topography increases with thickness of the coating, indicating that the deposited niobia may be filling in some of the recessed nanotextured features of the electrodeposited Pt.

The texture and composition of the Pt sample coated with a 3 nm thick layer of Nb_2O_5 was further analyzed by transmission electron microscopy (TEM) and energy dispersive X-ray spectroscopy (EDS) techniques (Fig. S3†). The samples were prepared by gently scraping the supported electrodes and suspending the obtained particulates in an ethanol solution to subsequently deposit them onto a TEM grid. The STEM and EDS images in Fig. S3† depict textured Pt particles with layers of niobium covering one-half of the particles, which were likely electrodeposited particles that had been a part of the mesoporous Pt substrate. These results were consistent with a partial coverage of Nb expected for these samples since the remainder of the Pt particle would have been either attached to the planar Pt support (prepared by PVD) or adjacent to other electrodeposited Pt particles. The layer of Nb visualized by EDS mapping was not perfectly uniform but had an average thickness of $2.5 \pm 0.7 \text{ nm}$. It is possible that some of the non-uniformity of the niobia films arose from the harsh methods used during sample preparation (e.g., mechanical treatment of the substrate used to isolate particles from their surfaces), resulting in some Nb_2O_5 being dislodged from the surfaces as shown in Fig. S3†.

The contrast between the electrical conductivity of the amorphous Nb_2O_5 coating (reported to be from 10^{-12} to $10^{-11} \text{ S cm}^{-1}$)³⁶ and that of the Pt substrate ($9.4 \times 10^4 \text{ S cm}^{-1}$) enabled another means of independently evaluating the coverage of the Nb_2O_5 films on the nanotextured Pt. Conductive atomic force microscopy (C-AFM) techniques were used to assess the uniformity of the niobia coatings through the use of this electrical contrast. By measuring the electrical conductivity of the sample while simultaneously mapping the surface



morphology, it was possible to gain information with regards to the surface coverage of the Nb_2O_5 films upon the intact electrodeposited Pt substrates (*i.e.*, without mechanical damage used to prepare the TEM samples). It was clear from conducting these measurements that the atomic layer deposited Nb_2O_5 coating was not as uniform or conformal as expected, which was more apparent for the thinner coatings of niobia (Fig. 2, 3c and d). As shown in Fig. 3, the measured electrical conductivity of the pristine Pt sample is an order of magnitude larger than that for the Nb_2O_5 coated samples as expected. This difference is apparent when comparing the peak current values measured at different locations on each type of sample. Some of the measured values on the 0.5 nm thick niobia coated substrates agree with the observed conductivity of the pristine, uncoated electrodeposited Pt. The scales of the peak currents extended to negative values, which included a few measurements at negative currents that were likely the result of some local surface charges. As noted in the inset histograms in Fig. 3, the majority of the currents were positive values. The imaging of the Pt coated with a 3 nm thick layer of Nb_2O_5 revealed much more consistent surface properties with only some small spikes in the maps of the electrical conductivity therein (Fig. 3e and f, S4†). The observed trends suggest that the Nb_2O_5 coating, although it does not form a film with a uniform thickness, was able to successfully form an oxide coating across the nanotextured Pt sample at film thicknesses >3 nm. Interestingly, height variations within the samples did not correlate with the observed non-uniformities in the conductivity across each sample. The non-uniformity of the niobia coatings may be a consequence of both the Pt morphology and changes therein during the ALD process as a result of heating to 250 °C.

The presence of Nb_2O_5 on the surfaces of the coated Pt electrodes was further confirmed using X-ray photoelectron spectroscopy (XPS) measurements. The binding energies of Nb 3d measured from high resolution XPS spectra match closely with those of the Nb^{5+} species found in Nb_2O_5

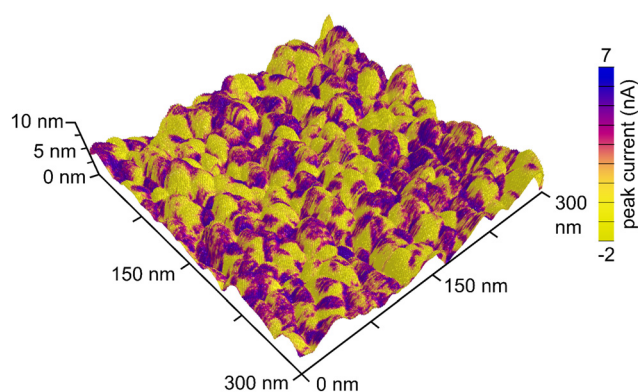


Fig. 2 Three-dimensional image of the topography of electrodeposited Pt coated with a 0.5 nm thick layer of Nb_2O_5 . The topography is overlaid with an electrical conductivity map (e.g., peak current values) as measured by conductive atomic force microscopy (C-AFM).

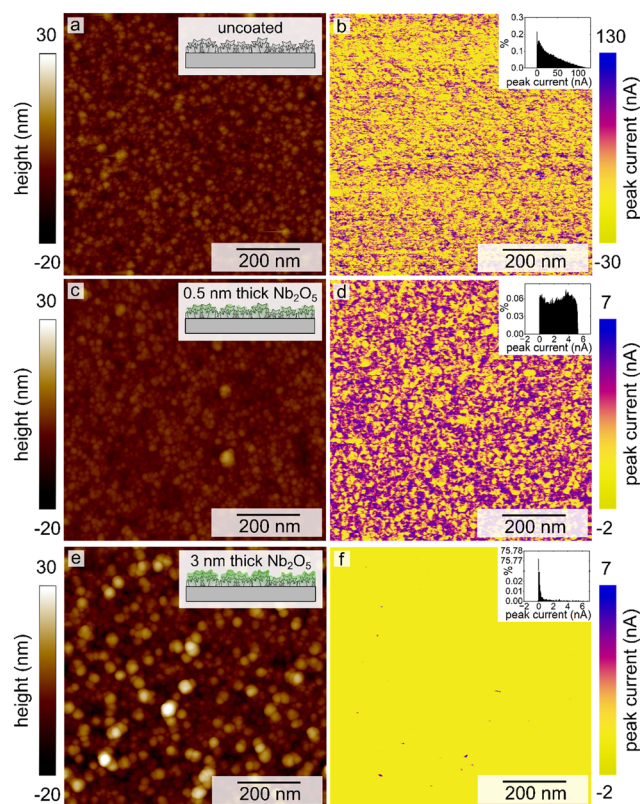


Fig. 3 Conductive atomic force microscopy images displaying the measured sample height (a, c and e) and peak current (b, d and f) for a pristine, uncoated electrodeposited Pt catalyst (a and b), and these nanotextured Pt catalysts after coating with a 0.5 nm (c and d) and a 3 nm thick layer of Nb_2O_5 (e and f). Histograms of the measured peak currents are plotted as insets to each, corresponding CAFM map.

(Fig. 4a, Table S1†). Additionally, the binding energies of Pt 4f were also observed, which corresponded to Pt metal species (Fig. 4b, Table S1†). The ratios of Pt:Nb for each type of sample were calculated from the atomic percentages obtained from the survey spectra. The ratio of Pt to Nb for each type of Nb_2O_5 coated, nanostructured Pt sample (*i.e.*, each film thickness evaluated herein) is plotted in Fig. 4d. The Pt:Nb ratio decreased with an increasing niobia film thickness, changing from 1.8 to 1.4 to 0.50 for the 0.5 nm, 3 nm, and 4.5 nm thick Nb_2O_5 films, respectively. This trend supports the presence of Nb_2O_5 films of an increasing thickness across this series of samples. As the thickness of the Nb_2O_5 layer increases, fewer photoelectrons from Pt are able to pass through the film to reach the detector, leading to a decreased signal for Pt relative to that of the Nb species. The non-linear nature of the trend is, however, indicative of a non-uniform thickness of the Nb_2O_5 coating, which is consistent with the results of both the TEM and C-AFM imaging.

Cyclic voltammetry-based analyses of both the pristine (uncoated) and niobia coated films of the nanotextured Pt exhibited characteristic Pt oxidation and reduction peaks from ~ 0.8 to 1.2 V_{RHE} and ~ 1.1 to 0.6 V_{RHE} , respectively (Fig. 1b). Both types of samples also exhibited hydrogen underpotential



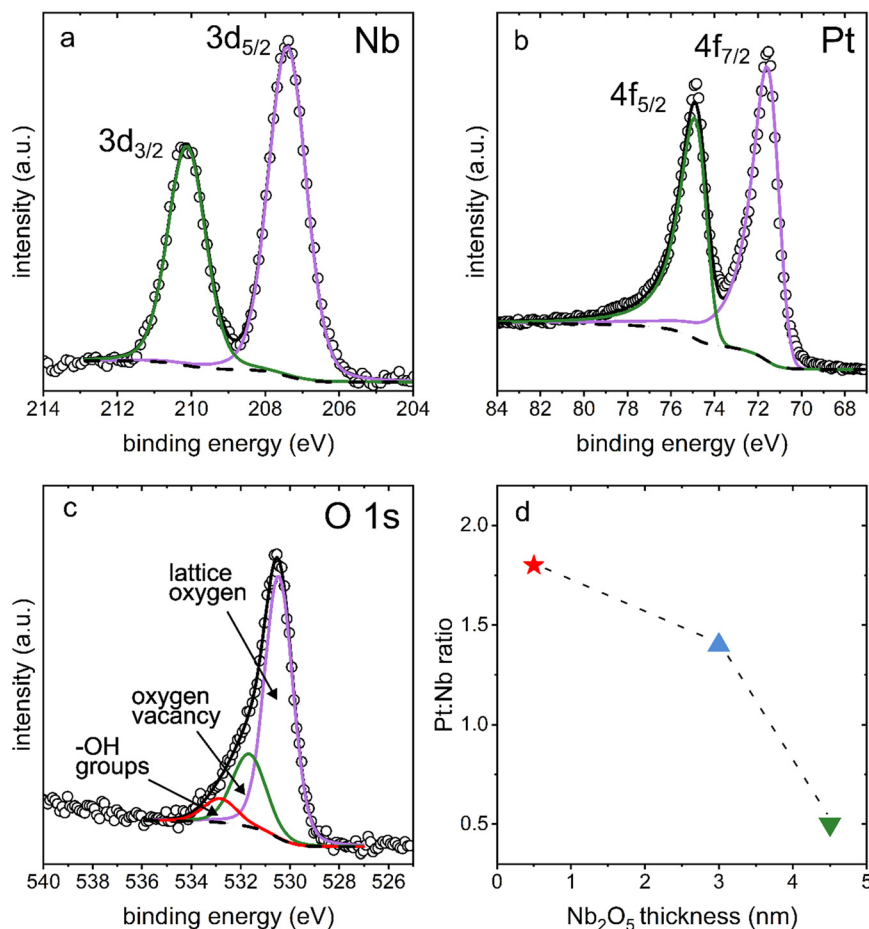


Fig. 4 High-resolution X-ray photoelectron spectroscopy (XPS) analyses of the (a) Nb 3d, (b) Pt 4f, and (c) O 1s species present in the nanostructured Pt samples coated with a 3 nm thick film of Nb₂O₅. Raw data are plotted as hollow circles, and the overall fits are plotted as solid lines. (d) Plot of the ratio of Pt : Nb as calculated from survey spectra of the electrodeposited Pt after coating with (red star) 0.5 nm, (blue triangle) 3 nm, and (green triangle) 4.5 nm thick films of Nb₂O₅. The dashed line was added to draw notice to the non-linearity of the three plotted Pt : Nb ratios.

deposition (H_{UPD}) from ~ 0.05 to 0.4 V_{RHE}. The A_{ecsa} , which is proportional to the integrated area of the H_{UPD} region, is negatively impacted by the presence of the Nb₂O₅ coating as seen in a relative decrease of the H_{UPD} peak intensities with a proportional increase in the thickness of the Nb₂O₅ layer. The striking impact of the coating on the accessible Pt surface area was unexpected based on the previously observed negligible impact of a 3 nm thick Nb₂O₅ coating on the A_{ecsa} of a thin film Pt catalyst.³⁰ The reason for this is, however, attributed to the differences in morphology of each type of catalyst used in these separate studies. Herein, the catalyst was prepared specifically to have a high surface area (more akin to the mesoporous Pt demonstrated in prior studies) through the electrodeposition of Pt in the presence of Brij-78 to create Angstrom-to-nanoscale pores.^{6,7,26,27,29} In contrast, the thin Pt film prepared by Eastcott *et al.* had a morphology more akin to the initial, planar Pt substrates used herein that were prepared by PVD techniques (Fig. S2a†).³⁰ These relatively smooth Pt substrates were used herein as supports to prepare the nanotextured films using Pt electrodeposition in the presence of a surfactant. The presence of pores in these nanotextured films likely had dimensions

proportional to or smaller than the thickness of the niobium oxide coating, which could lead to a non-uniform deposition of the oxide. It is likely that the oxide coating could have sealed some or all of these relatively narrow pores, making the surfaces within them inaccessible to the electrolyte.³⁷ The C-AFM studies demonstrated changes to the surface properties (*i.e.*, electrical conductivity) of the nanotextured catalyst after coating with different thicknesses of the Nb₂O₅. The results suggest that the deposited Nb₂O₅ layers are fairly uniform but the mass transport (including proton transport when probing the H_{UPD} region) could be hindered in some regions depending on the strength of the field lines within the pores *versus* at the outer edges of the coated pores.³⁸ As a result, the surface areas as measured by the adsorption of species from the electrolyte would be hindered in the case of the coated samples.¹³ In addition, the observed changes in morphology of the Pt catalyst after the coating procedure (*e.g.*, the heat treatment) could also contribute to the differences observed in the A_{ecsa} between the pristine and coated catalysts.

Methods for measuring the A_{ecsa} of Pt catalysts such as by H_{UPD} and Cu_{UPD} have been thoroughly investigated in the



literature.^{39,40} The addition of a metal oxide coating can change the properties of the catalyst surface, which is why two separate techniques to measure the A_{ecsa} were employed herein. These two techniques can also be used to investigate the presence of cracks in a coating layer, as well as to probe the transport of species through a coating as a function of varying scan rate.¹³ The use of either technique to measure the A_{ecsa} of the metal oxide coated catalysts can also reveal additional properties of the metal oxide overlayer including its ability to protect the catalyst against catalyst poisoning species.¹³ When evaluating the A_{ecsa} as measured by H_{UPD} at different scan rates, changes therein could arise from the influence of the metal oxide coating on the rates of adsorption and desorption, as well as diffusion of reactants through the coating. Prior studies have demonstrated a decreased A_{ecsa} at higher scan rates when the H^+ had to diffuse through relatively thick metal oxide coatings.¹³ Interestingly, the A_{ecsa} measured by H_{UPD} for the Nb_2O_5 coated catalysts barely changed ($\leq 3\%$) with an increase in the scan rates even for the sample with the 4.5 nm thick niobia coatings (Table 1). This suggests that the coating is able to facilitate the transport of protons to the catalyst surfaces, which could be assisted through Å-level pores in the layer of Nb_2O_5 . An increase in Nb_2O_5 coating thickness did, however, have an impact on the A_{ecsa} as measured by Cu_{UPD} . The Cu_{UPD} method measured $\sim 85\%$ of the A_{ecsa} obtained by integrating the H_{UPD} region for both the uncoated and 0.5 nm Nb_2O_5 coated sample. The measured Cu_{UPD} relative to the H_{UPD} dropped to $\sim 55\%$ for the samples coated with either a 3 nm or 4.5 nm thick layer of Nb_2O_5 . The access of Cu^{2+} to the Pt surface was hindered by the presence of the thicker Nb_2O_5 coatings, which is indicative of the surface coverage of the thicker coatings and their ability to block potential contaminants from poisoning the catalyst surfaces.

The difference in activity between the pristine and niobia coated catalysts towards the oxygen reduction reaction was initially quite large. The difference in onset potential was initially ~ 30 mV at -0.02 mA $\text{cm}_{\text{ecsa}}^{-2}$. Following 100 cycles of the accelerated stress test (AST), the activity normalized against the A_{ecsa} from H_{UPD} for the coated catalysts overlapped with the normalized activity observed for the pristine Pt catalyst (Fig. S5a and c†). Electrochemical impedance spectroscopy (EIS) was used to assess changes in the capacitances and resistances of these systems throughout

the AST. The EIS results exhibited a similar trend to the changes in A_{ecsa} as a function of applying the AST. As the AST progressed, the charge transfer resistance of the niobia coated catalysts decreased and approached the resistance of the pristine Pt catalyst (Fig. S5b and d†). The increased activity and decreased charge transfer resistance of the Nb_2O_5 coated catalysts over 100 cycles of the AST was accompanied with an increase in its A_{ecsa} (Fig. S6†). The most significant changes were observed within the first 100 cycles of the AST for the coated samples, but the pristine samples were more consistent over this same duration of the AST. It is possible that the niobia coated samples may require an increased number of cycles to reach a stable state in comparison to the pristine Pt catalyst. This prolonged period of activation could be due to mass transport limitations of the Nb_2O_5 layer, which would need to be accounted for in any protocols for handling these coated Pt catalysts.

Comparing the longer term performance of the pristine and coated catalysts

The accelerated stress tests were selected to specifically target Pt degradation mechanisms that are triggered by repeating Pt oxidation and Pt oxide reduction. An example of a cyclic voltammetry plot depicting a single, representative cycle of the AST is provided in Fig. S7†. Changes to the morphology of the pristine Pt catalyst when comparing the sample before and after 500 cycles and 1000 cycles of the AST can be seen in the SEM images presented in Fig. S8†. The initial Pt texture contained faceted and dimpled surface features, which were transformed into porous, branched structures with smoother features. On the other hand, the catalyst coated with a 3 nm thick layer of Nb_2O_5 exhibited relatively little change in its morphology after 500 cycles of the AST (Fig. S8b and d†). After 1000 cycles of the AST, the SEM images of the niobia coated sample exhibited slightly smoother features (Fig. S8f†). It is at this stage that the coated Pt catalyst appears to exhibit a similar morphology to that of the pristine Pt catalyst after its AST (*i.e.*, the initial stages of a transition to a smoother porous structure at the surface of the Pt). This trend is more clearly observable for the catalyst coated with the 0.5 nm thick layer of Nb_2O_5 (Fig. S9†). The initial morphology of this catalyst contains relatively jagged features with a relatively sharp contrast, but as the catalyst is

Table 1 The electrochemically active surface area (A_{ecsa}) as determined by different techniques for the pristine nanostructured Pt and nanostructured Pt coated with Nb_2O_5

Nb_2O_5 thickness (nm)	A_{ecsa} (cm_{geo}^2) from H_{UPD}		A_{ecsa} (cm_{geo}^2) from Cu_{UPD}
	10 mV s^{-1} ^a	200 mV s^{-1} ^a	
n/a	7.8	7.3	6.8
0.5	6.0	5.9	5.1
3	5.6	5.7	3.2
4.5	4.3	4.4	2.4

^a Scan rate used to cycle the applied potential.



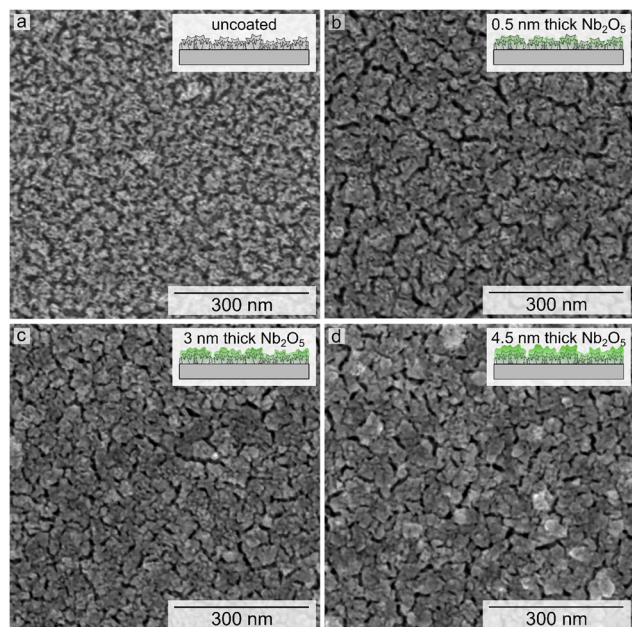


Fig. 5 A series of scanning electron microscopy (SEM) images of (a) pristine Pt with a nanoscale texture and the same substrate after coating with a (b) 0.5 nm, (c) 3 nm, and (d) 4.5 nm thick layer of Nb₂O₅. These images were taken after 1000 cycles of an AST.

electrochemically cycled the cracks or recesses between the features widen with progression of the testing along with the formation of smoother, porous features. A comparison of the morphology of the uncoated and coated samples after 1000 AST cycles is portrayed in Fig. 5 showing that an increase in the thickness of the Nb₂O₅ coating is associated with smaller changes in morphology and catalyst re-structuring.

The textures of the pristine Pt catalyst and the catalyst coated with 0.5 nm thick layer of Nb₂O₅ adopt morphologies after electrochemical cycling similar to those textures observed for dealloyed nanoporous materials.^{41,42} The morphologies of such dealloyed materials are understood to evolve from bulk alloys into nanoporous structures through a surface-diffusion based process. The proposed model for this process proceeds through a dissolution of one of the alloyed metals. The surface atoms of the remaining metal(s) are undercoordinated and coalesce with the other undercoordinated atoms to form islands through surface migration. As one metal continues to dissolve from the surfaces of the newly exposed alloy, the undercoordinated metal that remains in the substrate will continue to lead to further coalescence and the formation of branched, nanoporous networks.^{41,42} Although the work reported herein does not utilize a metal alloy, the AST is designed to induce a process of Pt dissolution that is akin to removing one metal from an alloy. As some Pt atoms dissolve into the electrolyte, the undercoordinated Pt atoms remaining at the surfaces of the catalyst appear to undergo a similar process of coalescence and formation of similarly branched, nanoporous structures. It is likely that the changes observed in the surface features of the pristine Pt and niobia coated Pt proceed through surface migration. The results further suggest that the Nb₂O₅ coating is

hindering the process of reconstruction due to the relatively consistent morphology observed for the niobia coated Pt both before and after the AST (Fig. S8 and S9†).

The evolution of the samples coated with thicker layers of Nb_2O_5 (*i.e.*, 3 nm and 4.5 nm) as prepared by atomic layer deposition is, however, distinct from that observed in the pristine nanostructured Pt and the Pt coated with a thinner coating of Nb_2O_5 (*i.e.*, 0.5 nm thick niobia). After 5000 cycles of the AST, the Pt coated with the thicker layers of niobium oxide exhibit a series of relatively flat islands bounded by circular recesses (Fig. S10[†]). Analysis by C-AFM of the sample coated with 3 nm Nb_2O_5 after 5000 cycles of the AST showed no change in the surface electrical conductivity of the sample (Fig. S10c and d). Analysis by XPS demonstrated that the Pt: Nb ratio for the sample coated with a 3 nm thick layer of Nb_2O_5 increased from 1.4 prior to any AST cycles to 18 after the sample was subjected to 5000 AST cycles. The large decrease in the Nb signal relative to the Pt signal suggests that after 5000 AST cycles, a majority of the Nb_2O_5 film has been either dissolved or dislodged from the electrode surface despite the electrical conductivity remaining unchanged.

The layer of Nb₂O₅ successfully mitigated catalyst restructuring for up to at least 1000 cycles of the AST and the presence of the coating evidently affects the surface migration behaviour of the Pt atoms. Surface restructuring of the Pt can result from the processes of oxidation and subsequent reduction of the Pt oxide, such as during the transformation from chemically adsorbed oxygen to the incorporation of the oxygen into the Pt lattice.^{43–45} Additional surface reconstruction can result from the dissolution of Pt species into the electrolyte.^{46–48} The mechanistic role of the Nb₂O₅ coating is unclear from the observed trends in the changes in morphology (Fig. S8 and S9†) and the corresponding electrochemical response of each sample (Fig. 6 and S6†). To test the presence of dissolved platinum, aliquots of the electrolyte were analyzed by inductively coupled plasma-mass spectrometry (ICP-MS) following a set number of cycles in the AST (Fig. S11†). The ICP-MS results demonstrated that the pristine Pt electrode produced a slightly larger mass of dissolved Pt per geometric area ($24.3 \pm 0.2 \mu\text{g Pt cm}_{\text{geo}}^{-2}$) compared with the Pt electrode coated with 3 nm thick layer of Nb₂O₅ ($19.9 \pm 0.3 \mu\text{g Pt cm}_{\text{geo}}^{-2}$). In addition, the amount of Pt dissolution increased in a linear manner over the course of 5000 cycles of the AST. Since the Nb₂O₅ does not mitigate the majority of Pt dissolution, the differences between the coated and pristine catalyst morphologies after extensive AST cycling must be a result of the interaction between the undercoordinated Pt atoms and the Nb₂O₅. Calculations of the interaction between Pt and the oxygen in Nb₂O₅ in a bilayer catalyst show a strong adsorption energy compared with other niobium oxides.⁴⁹ Further support for the mechanism behind the stabilization of the electrodeposited Pt by Nb₂O₅ lies in the many studies of Pt single atom catalysts showing that they can be stabilized on metal oxide supports by binding to excess oxygen species at the surface.^{50–52}

After the AST, the activity of the catalyst towards the ORR was also probed by linear sweep voltammetry and electrochemical

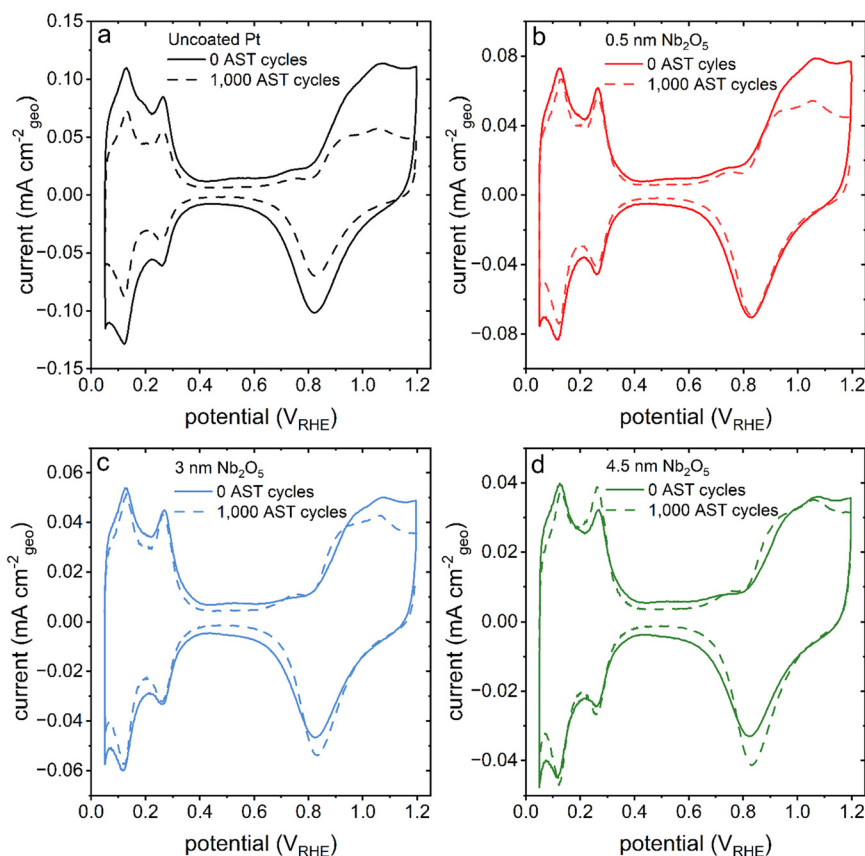


Fig. 6 A series of cyclic voltammetry plots corresponding to the nanotextured Pt catalysts (solid line) before and (dashed line) after 1000 cycles of an accelerated stress test (AST). The colours of the traces correlate to differences in thickness of the Nb₂O₅ coatings, where (a) black represents uncoated or pristine nanotextured Pt, and (b) red is 0.5 nm, (c) blue is 3 nm, and (d) green is 4.5 nm thick niobia coated nanotextured Pt.

impedance spectroscopy techniques. The onset potential towards the ORR determined by linear sweep voltammetry was found to shift towards more negative potentials only for the pristine Pt catalyst (Fig. 7). The onset potential of the Nb₂O₅ coated catalysts remained relatively constant after 1000 cycles of the AST (Fig. 7 and S12[†]). The relatively high potentials used to perform these tests predominantly probed the charge transfer resistances of these systems.⁵³ The charge transfer resistance of the pristine Pt catalyst increased by $\sim 30 \text{ } \Omega \text{ cm}_{\text{ecsa}}^{-2}$ while the same resistance for the coated catalysts increased by $\sim 20 \text{ } \Omega \text{ cm}_{\text{ecsa}}^{-2}$ over the course of the 1000 AST cycles (Fig. S6b[†]). These results collectively suggest that the Nb₂O₅ coating had a stabilizing effect on the activity of the Pt catalyst, in addition to its influence on the sample morphology.

This study was conducted to build upon previous work that showed, *via* electrochemical techniques, an improved durability of PVD Pt coated with nanoscale, ~ 3 nm thick films of Nb_2O_5 in comparison to bare PVD Pt. This work aimed to understand how these coatings performed when applied to more realistic Pt fuel cell catalysts with higher surface areas and nanoscale features.³⁰ By working with the porous, electrodeposited Pt substrate used herein it became apparent that the design of niobia coated high surface area catalysts should be carefully considered to maintain the accessible surface area after applying the coating (*e.g.*, ensure

that pore and feature sizes are large enough that the coating is not able to fill in areas of the catalyst such that they are inaccessible to the electrolyte). This work saw similar stabilization of the catalyst activity and an improvement in the stabilization of the A_{ecsa} . It was suggested that the cause of the improved durability of the ~ 3 nm Nb_2O_5 layer was that the coating was mitigating Pt dissolution for both the PVD Pt catalysts and the electrodeposited Pt catalysts presented here. But a series of ICP-MS studies demonstrated that the mitigation of Pt dissolution was less than expected. Instead, it is hypothesized that the Nb_2O_5 coating increases the durability of the Pt by forming bonds between the undercoordinated surface Pt and O atoms in the Nb_2O_5 . Additional work should be pursued with regards to the method(s) used to prepare the niobia coating to improve its impact on the nanostructured Pt, as well as to further correlate the nanoscale structure (*e.g.*, porosity) and texture (*e.g.*, including its atomic-scale uniformity) of the niobia film to the potential for Pt dissolution and the observed mechanisms for improved Pt durability.

Conclusions

A porous, high surface area Pt catalyst was synthesized by electrodeposition techniques in the presence of templates self-

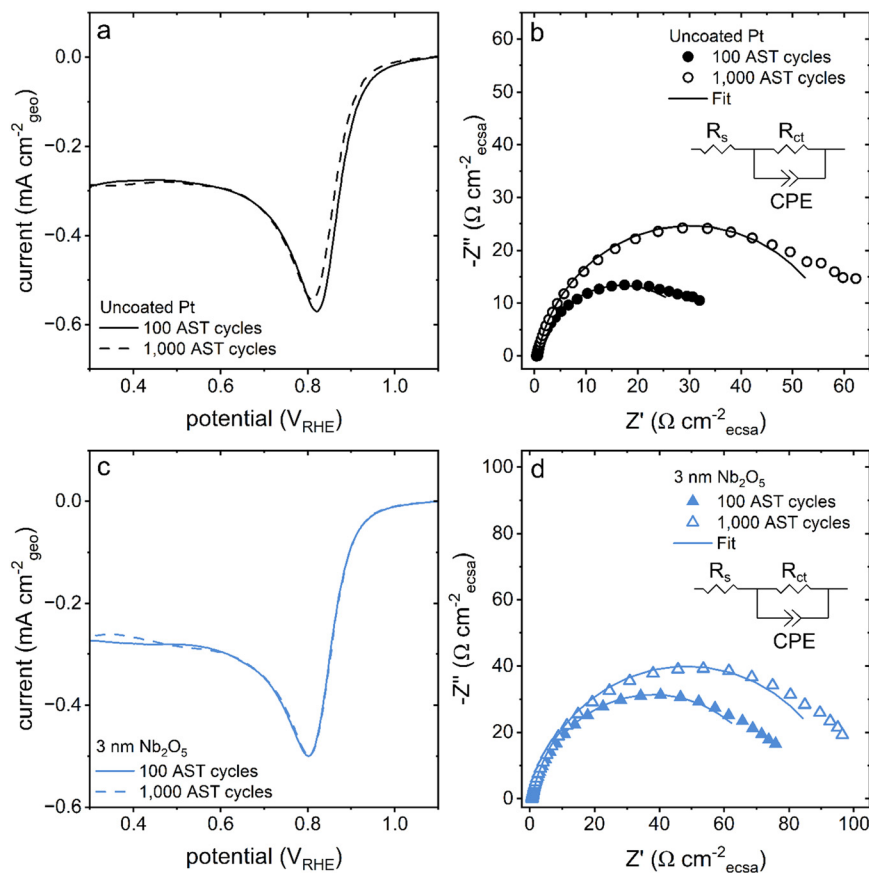


Fig. 7 (a and c) Linear sweep voltammetry plots recorded at a scan rate of 10 mV s^{-1} in an O_2 (g) saturated electrolyte for the pristine and coated Pt samples after performing (solid line) 100 cycles and (dashed line) 1000 cycles of the AST. (b and d) Nyquist plots recorded at $0.9 V_{\text{RHE}}$ in an O_2 saturated electrolyte with fits (solid lines) corresponding to the circuit displayed in the inset also obtained after performing (solid symbols) 100 cycles and (hollow symbols) 1000 cycles of the AST. The colours of the traces correspond to the thickness of the Nb_2O_5 films where black is uncoated, pristine Pt and blue is Pt with a 3 nm thick coating of Nb_2O_5 .

assembled from surfactants. The resulting nanostructured Pt catalyst was subsequently coated with different thicknesses of Nb_2O_5 using atomic layer deposition as confirmed by XPS and C-AFM, and this series of samples each exposed to an aggressive stress test designed to target Pt dissolution and re-structuring processes. In comparison to previous tests on planar Pt coated with Nb_2O_5 ,³⁰ the three-dimensional structure of the Pt catalyst synthesized in this work enabled a more rigorous study of the stabilizing effect of the metal oxide coating. The durability of the catalyst was specifically evaluated as a function of the thickness of the applied niobium oxide coatings. Analysis of the samples did, however, reveal that the coating was not perfectly uniform across the surfaces of the textured Pt catalyst. This lack of uniformity is the likely reason that the dissolution of Pt was not as mitigated as expected, although the thicker (3 to 4.5 nm thick) non-uniform coatings were highly effective at stabilizing the catalyst morphology under aggressively oxidizing and reducing conditions. Furthermore, this work found that a coating with a thickness of 3 nm was able to both stabilize the catalyst structure over a range of applied potentials while minimizing the charge transfer resistance towards the ORR, which increased with the thickness of the niobia coating. In

future studies, techniques such as *in situ* electrochemical TEM^{54,55} or single particle ICP-MS⁵⁶ would be instrumental in probing the mechanism of re-structuring in the presence of metal oxide coatings. These techniques could show the distributions of the coating and platinum oxide in the catalyst during the processes of oxidation and reduction⁵⁷ and could elucidate the mechanism(s) by which the catalyst is degrading (e.g., dissolution into Pt ions or by nanoparticles being dislodged from the surface).⁵⁸ The knowledge gained over the course of this study can be used in the endeavor to stabilize nanomaterials to both decrease the financial investment and increase the lifetime of these materials for a variety of applications.

Experimental section

Electrode fabrication

Electrodeposition of platinum catalysts. The working electrode used for Pt electrodeposition consisted of a $\sim 1 \text{ cm} \times 2 \text{ cm}$ section of polished Si wafer that was coated with 10 nm Ti followed by a 200 nm thick layer of Pt *via* electron beam assisted evaporation using a Lesker PVD 75 deposition system in a Class



100 clean room at 4D LABS. Prior to this deposition process, the chamber was held at 2×10^{-6} Torr and the substrate was rotated at 20 rpm. The deposition rates of the Ti and the Pt were measured to be $\sim 0.5 \text{ \AA s}^{-1}$ and $\sim 1.5 \text{ \AA s}^{-1}$, respectively, using a quartz crystal microbalance. The two steps of material deposition (Ti and then Pt) were performed without breaking the vacuum between each step. The subsequent Pt electrodeposition was conducted using a cylindrical graphite rod (Alfa Aesar, United States) as the counter electrode, and an Ag/AgCl electrode with a 3 M KCl filling solution (Alfa Aesar, United States) as the reference electrode. The potential of the Ag/AgCl electrode was measured to be 0.23 V against a custom-built reversible hydrogen electrode (RHE) in 0.5 M H_2SO_4 . Prior to Pt electrodeposition, sections of the Pt coated wafers were rinsed successively with deionized (DI) water with a resistivity of 18.2 M Ω cm as prepared using a Barnstead Diamond™ system. Each substrate was subsequently rinsed with anhydrous ethanol (Commercial Alcohols). Finally, the wafer was dried under a stream of filtered, compressed N_2 (g). To electrochemically clean each section of wafer, the wafer pieces were individually cycled 20 $\times$ between the potential of 1.0 V and -0.2 V (vs. RHE) at a scan rate of 100 mV s^{-1} while immersing the substrate in 0.5 M H_2SO_4 (Reagent Grade, Caledon Laboratory Chemicals). The cleaned wafer sections were further rinsed with DI water and dried under a stream of N_2 (g). A $\sim 1 \text{ cm}^2$ section of the wafer was submerged in the aqueous 5 mM H_2PtCl_6 [$\sim 40\%$ Pt, Sigma-Aldrich (United States)] and 0.06 mM Brij-78 [Sigma-Aldrich (United States)] electrodeposition solution and a Metrohm PGSTAT 302N potentiostat was used to apply the potentiostatic electrodeposition conditions. The Pt was electrodeposited using a double pulse deposition method in which a more negative potential was initially applied to the working electrode to induce Pt nucleation followed by the application of a less negative potential to promote the growth of the Pt layer. The nanostructured Pt layer was electrodeposited by applying a potential of -0.6 V for 30 s followed by -0.2 V for 120 s. After Pt deposition, Devcon® 5 Minute® Epoxy was applied to the regions of the electrode above the layer of electrodeposited Pt such that the electrode surface area exposed to the electrolyte would remain constant between different steps of electrochemical and structural characterization. Each of the electrodes were thoroughly rinsed with DI H_2O and dried under a stream of compressed, filtered N_2 (g) prior to coating with niobia and further characterization.

Atomic layer deposition of niobium oxide. The Nb_2O_5 layer was deposited on top of the electrodeposited Pt *via* a thermally assisted atomic layer deposition (ALD). The prepared $\sim 1 \text{ cm} \times 2 \text{ cm}$ electrodes were placed in the sample chamber of a Cambridge NanoTech Fiji F200 ALD system in a Class 100 clean room in 4D LABS at SFU. The substrates were transferred to the reaction chamber, which was placed under high vacuum and purged with high purity Ar gas (99.999% Praxair). The electrodes and reaction chamber were pre-heated to 250°C and the Nb precursor [TBTDEN (*tert*(butylimino)tris(diethylamido)niobium), Sigma Aldrich] was pre-heated to 65°C at least 2 h prior to use and both the

substrate and precursor maintained at these respective temperatures throughout the deposition process. The reaction chamber pressure was held at 0.0156 Torr and the Ar carrier gas and Ar plasma flow rates were set to 60 sccm and 200 sccm, respectively. One cycle of the ALD process consisted of the following steps: (i) TBTDEN was introduced for 1 s into the chamber; (ii) Ar gas was introduced for 0.5 s; (iii) these two steps were repeated for a total of three times; (iv) water vapour was introduced into the chamber for 0.06 s; and (v) the chamber was purged with Ar gas for 0.5 s. This process was repeated until achieving the desired thickness of Nb_2O_5 . The method described here was previously used in Eastcott *et al.* and found to have a deposition rate of $\sim 1 \text{ \AA}$ per cycle. Moreover, the prior study determined that 270 deposition cycles resulted in a film of $\sim 3 \text{ nm}$ thickness.²⁰ The wafer electrodes characterized in this work were coated with Nb_2O_5 of a series of different thicknesses. Since 90 cycles corresponded to an approximate thickness of 1 nm, the 0.5 nm, 3 nm, and 4.5 nm Nb_2O_5 coated samples underwent 45, 270, and 405 ALD cycles, respectively.

Material Characterization

Conductive atomic force microscopy. The electrical conduction between the surfaces of each electrocatalyst and the stage were maximized by coating the sides and bottom of each sample with a silver paint. Conductive atomic force microscopy (C-AFM) images were acquired with a Bruker Dimension Icon atomic force microscope with a PF-TUNA probe coated with Pt/Ir ($f_0 = 70 \text{ kHz}$, $k = 0.4 \text{ N m}^{-1}$). Images were acquired over scan areas of both $1 \mu\text{m} \times 1 \mu\text{m}$ and $300 \text{ nm} \times 300 \text{ nm}$ with a scan speed of $\sim 0.5 \text{ Hz}$ and a resolution of 512 by 512. Peak currents and TUNA currents were measured using a tunneling mode (TUNA) with a 1 V bias. The images were analyzed using NanoScope Analysis (Version 2.00).

Scanning electron microscopy. Scanning electron microscopy (SEM) was used to characterize the morphology of the catalyst before and after the electrochemical characterization. This imaging was conducted using a Helios NanoLab 650 operated with an accelerating voltage of 5 kV and at a probe current of 100 pA. Samples for SEM were fixed to Al stubs with a conductive carbon tape.

Transmission electron microscopy. Transmission electron microscopy (TEM) was used to characterize the morphology of the catalyst and the niobia coating. This imaging was conducted using an FEI Osiris X-FEG S/TEM operating at 200 kV. A plastic micropipette was used to carefully detach the electrodeposited platinum and niobia structures from the PVD platinum substrate. Ethanol (10 μL) was then added to the surface to suspend the detached particles to be drop cast onto Formvar/carbon-coated 300 mesh copper TEM grids (PELCO®, Ted Pella Inc., United States).

X-ray photoelectron spectroscopy. Samples were analyzed by X-ray photoelectron spectroscopy (XPS) using a Kratos Axis Ultra system equipped with a monochromatic Al $K\alpha$ source and a delay line detector (DLD). The samples were secured to



a copper sample bar for use with high vacuum XPS analyses. A survey scan of each sample was acquired over binding energies (BE) from 1200 eV to 0 eV and a flood gun was used as a charge neutralizer. The adventitious C 1s peak at 284.8 eV was used for the calibration of the BE and a Shirley fit background subtraction was applied to the high-resolution scans using CasaXPS software (version 2.3.16). The Kratos Axis Ultra DLD relative sensitivity factors were used for quantification.

Inductively coupled mass-spectrometry. A Thermo Scientific iCAP Qc inductively coupled plasma mass-spectrometer (ICP-MS) enabled quantification of the amount of platinum dissolved into the electrolyte after specific electrochemical tests. Glassware used to prepare samples for ICP-MS were soaked in 10% HNO₃ (extra pure, 60% solution in water, Acros Organics) for at least 24 h. The electrochemical cell was cleaned with standard clean-1 (SC-1, *i.e.*, ammonia and hydrogen peroxide mixture) to remove the organic and particulate contaminants and with standard clean-2 (SC-2, *i.e.*, hydrochloric acid and hydrogen peroxide mixture) to remove the metallic contaminants.^{59,60} The electrochemical cell was washed with DI water between and after these cleaning steps. **Caution:** ammonia, hydrogen peroxide and hydrochloric acid are highly corrosive. The necessary safety protocols must be followed when working with these reagents. Platinum standards for ICP-MS were prepared from a Pt stock solution (Platinum Standard for ICP TraceCERT®, Sigma-Aldrich) and diluted in 99:1 (v:v) solution of 2% HNO₃:0.5 M H₂SO₄. The Pt standards were used within two weeks of their preparation. The subsequent dissolution of Pt from the electrodeposited films into the electrolyte during electrochemical testing was measured by taking 1 mL aliquots of the electrolyte at various intervals throughout a 5000 cycle AST. During the AST, the electrochemical cell was held at 25 °C and purged with N₂ gas (99.999%, Linde Canada). The aliquot was then diluted 100× in 2% HNO₃ and 1 mL of fresh electrolyte was added to the electrochemical cell to maintain the initial electrolyte volume. The samples were analyzed by ICP-MS on the same day that they were prepared.

Electrochemical characterization

All electrochemical characterization of the custom electrocatalysts were conducted while immersing the samples in 0.5 M H₂SO₄ at 25 °C in a three-electrode cell set up that was controlled using a Metrohm PGSTAT 302N potentiostat. A cylindrical graphite rod (Alfa Aesar, United States) was used for the counter electrode and a custom-built reversible hydrogen electrode (RHE) was used as the reference electrode. The upper, pristine half of the wafer supported electrocatalysts were held by a flat Cu clip soldered to a Cu wire that also provided an electrical connection during the characterization. Prior to the electrochemical analyses, the electrolyte was purged with N₂ gas (99.999%, Linde Canada) to displace dissolved O₂ gas. Each newly fabricated custom electrocatalyst was conditioned with *via* cyclic voltammetry

(CV) techniques, scanning the potential from 0.05 to 1.2 V_{RHE} at a scan rate of 50 mV s⁻¹ for 40 scans. Electrochemical analysis was also performed in O₂ (99.993%, Linde Canada) saturated electrolyte to test the activity of the catalyst towards the oxygen reduction reaction and to evaluate the effect of adding the Nb₂O₅ layer to the catalyst. Linear sweep voltammetry (LSV) scans were collected at a scan rate of 10 mV s⁻¹ and electrochemical impedance spectroscopy (EIS) measurements were collected at an applied potential of 0.9 V_{RHE} over the frequency range of 100 kHz to 0.1 Hz with an amplitude of 0.01 V. The accelerated stress test (AST) consisted of a series of CVs collected at a scan rate of 500 mV s⁻¹ over the potential range from 0.6 to 1.5 V_{RHE} for up to 5000 cycles.

The A_{ecsa} for each substrate was calculated from an average of the areas associated with the hydrogen underpotential adsorption and desorption regions recorded in the CV scans collected at a scan rate of 10 mV s⁻¹ in N₂ gas saturated 0.5 M H₂SO₄ electrolyte. The current arising from the double-layer capacitance was subtracted, applying the standard method for baseline correction.⁶¹ A conversion factor of 210 μC cm⁻² for Pt was employed to convert the charge calculated from the region of hydrogen underpotential deposition into the A_{ecsa} values for the Pt catalyst.⁶² The underpotential deposition of copper (Cu) was separately used to investigate the electrode surface areas. The desorption of underpotentially adsorbed Cu atoms was recorded by linearly scanning the potential from 0.36 V_{RHE} to 1.0 V_{RHE} at a scan rate of 10 mV s⁻¹ or 20 mV s⁻¹ after holding the electrode at 0.36 V_{RHE} for 50 s in 0.5 M H₂SO₄ and 2 mM CuSO₄ (ReagentPlus®, ≥98.0%, Sigma-Aldrich).¹³ A conversion factor of 420 μC cm⁻² for Pt was employed to convert the charge calculated from the underpotential deposition of Cu into the A_{ecsa} for the Pt catalysts.

Data availability

The data that support the findings of this study are available from the corresponding author upon reasonable request.

Conflicts of interest

The authors confirm no competing financial interest.

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